576 Hac'o Pluie:

pto use only

* - T	L FEE (37 CFR 1.492(A)(09/647207			
Search Report	has been prepared by th	CT/PTO 2 7 SEP 2000			
International p	reliminary examination fe	e paid to USPTO (37 CFF	430 Rec'd P	<u> </u>	SEP 2000
	al preliminary examinatior al search fee paid to USP				
		nation fee (37 CFR 1.482) (a)(2)) paid to USPTO			
		e paid to USPTO (37 CFF			
and all claims	satisfied provisions of PC	T Article 33(2)-(4)	\$94.00		
					T
	ENTER APPRO	PRIATE BASIC I	FEE AMOUNT =	\$420.00	
	for furnishing the oath or o st claimed priority date (3	declaration later than \Box 2 7 CFR 1.492(e)).	0 ■ 30	\$ 65.00	
CLAIMS	NUMBER FILED	NUMBER EXTRA	RATE		
Total claims	22 - 20 =	2	× \$22.00	\$ 44.00	
Independent claims	- 3 =	0	× \$78.00	\$0	
MULTIPLE DEPENDE	NT CLAIM(S) (if applicab	le)	+ \$250.00	\$	
		TOTAL OF ABOVE	CALCULATIONS =	\$0 —————————	
Reduction of ½ for filing be filed (Note 37 CFR		able. Verified Small Entity	Statement must also	\$1,014.00 	
A			SUBTOTAL =	\$507	
Processing fee of \$130 months from the earlies	0.00 for furnishing the Eng st claimed priority date (3	glish translation later than 7 CFR 1.492(f)).	□ 20 30	\$	
				\$	
		TOTAL	NATIONAL FEE =	Ψ	
Fee for recording the e		TOTAL CFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00	ment must be	\$	·
Fee for recording the e		OFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00	ment must be		
Fee for recording the e		OFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00	ment must be per property +	\$	\$
Fee for recording the e		OFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00	ment must be per property +	\$ \$507.00 Amount to be:	\$
Fee for recording the e accompanied by an ap	propriate cover sheet (37	CFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00 TOTAL F l	nent must be per property + EES ENCLOSED =	\$ \$507.00 Amount to be: refunded	
Fee for recording the e accompanied by an ap	propriate cover sheet (37) the amount of \$ 507.00	CFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00 TOTAL FI	nent must be per property + EES ENCLOSED =	\$507.00 Amount to be: refunded charged	
Fee for recording the e accompanied by an apparature as a check in b. Please cha A duplicate	the amount of \$507.00 arge my Deposit Account accopy of this sheet is enco	CFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00 TOTAL FI to cover the abov No in the amoun losed.	nent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the a	\$ \$507.00 Amount to be: refunded charged	\$
a. ☒ A check in b. ☐ Please cha A duplicate c. ☒ The Comm 500624	the amount of \$ 507.00 Trige my Deposit Account is copy of this sheet is encires is signer. A duplicate copy of this	CFR 1.21(h)). The assignr CFR 3.28, 3.31). \$40.00 TOTAL FI to cover the abov No in the amoun losed. It is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged above fees.	\$ o Deposit Account No.
a. ☒ A check in b. ☐ Please cha A duplicate c. ☒ The Comm 500624 NOTE: Where an app	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encirsioner is hereby authority. A duplicate copy of this ropriate time limit under	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged above fees.	\$ o Deposit Account No.
a. ☒ A check in b. ☐ Please cha A duplicate c. ☒ The Comm 500624 NOTE: Where an app	the amount of \$507.00 If you have a second to be copy of this sheet is encire is sistency authority. A duplicate copy of this ropriate time limit under orestore the application	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged above fees.	\$ o Deposit Account No.
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to SEND ALL CORRESPONDE	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged above fees.	\$ o Deposit Account No.
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$507.00 Amount to be: refunded charged above fees. credit any overpayment to the control of t	o Deposit Account No 1.137(a) or (b)) must
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to SEND ALL CORRESPONDE David Rubin FULBRIGHT & JAWOR	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged char	\$ o Deposit Account No.
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to SEND ALL CORRESPONDE David Rubin FULBRIGHT & JAWOR 666 Fifth Avenue	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged charged shove fees. Credit any overpayment to sign to revive (37 CFR SIGNATURE	o Deposit Account No 1.137(a) or (b)) must
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to SEND ALL CORRESPONDE David Rubin FULBRIGHT & JAWOR 666 Fifth Avenue New York, NY 10103	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged char	o Deposit Account No 1.137(a) or (b)) must
a. A check in b. Please cha A duplicate c. The Comm 500624 NOTE: Where an app be filed and granted to SEND ALL CORRESPONDE David Rubin FULBRIGHT & JAWOR 666 Fifth Avenue New York, NY 10103	the amount of \$507.00 arge my Deposit Account is copy of this sheet is encissioner is hereby authority. A duplicate copy of this ropriate time limit under the restore the application in the copy of the copy of the copy of this repriate time limit under the application in the copy of the copy of the copy of this restore the application in the copy of t	to cover the abov No in the amoun losed. zed to charge any fees w s sheet is enclosed.	rent must be per property + EES ENCLOSED = e fees is enclosed. t of \$ to cover the analysis and the cover the analysis and the cover the co	\$ \$507.00 Amount to be: refunded charged charged shove fees. Credit any overpayment to still the control of t	o Deposit Account No 1.137(a) or (b)) must

09/647207 430 Rec'd PCT/PTO 27 SEP **2000**

HUBR 1165

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

Stuke et al.

International

Appln. No.

PCT/EP99/02238

Filed

Herewith

For

ADHESIVE-FREE POLYMER COMPONENT JOINTS FOR

PRODUCING CLOSED MICRO- AND NANO-CHANNEL

STRUCTURES

Hon. Commissioner of Patents

September 26, 2000

and Trademarks

Washington, D.C. 20231

PRELIMINARY AMENDMENT

SIR:

Prior to examination, please amend the application as follows:

IN THE CLAIMS

Please cancel pending claims 1-22.

Please add the following claims 23-44, as follows:

- 23. A process for the adhesive-free production of polymeric components, including the steps of:
 - (a) preparing a polymeric substrate which, on at least one surface, has depressions forming micro- and/or nanochannel structures,

- (b) applying, by uniform pressure extending over the surface, a polymeric covering to a surface present on the substrate, said substrate having depressions but otherwise being smooth,
- (c) slowly heating the substrate, with the covering applied by pressure, to a temperature which is at least as high as the glass transition temperature of the substrate and/or of the covering, for the bonding thereof, and
- (d) cooling.
- 24. The process as claimed in claim 23, wherein the polymeric substrate and the polymeric covering are selected from the group consisting of acrylic polymers, polycarbonates, polystyrenes, and also copolymers and mixtures of these.
- 25. The process as claimed in claim 24, wherein the polymeric substrate and the polymeric covering are selected from the group consisting of acrylic polymers, in particular of polymethyl methacrylate polymers, or of polymeric carbonates.
- 26. The process as claimed in claim 23, wherein the substrate has depressions with a width or/and depth within the range from 10 nm to 2 mm.

27. The process as claimed in claim 26, wherein

the substrate has depressions with a width or/and depth within the range from $100\,\mathrm{nm}$ to $1\,\mathrm{mm}$.

- 28. The process as claimed in claim 27, wherein the substrate has depressions with a width or/and depth within the range from 1 μm to 500 μm .
- 29. The process as claimed in claim 23, wherein substrate and covering are selected from among polymeric materials of the same type.
- 30. The process as claimed in claim 23, wherein at least the covering is selected from among optically transparent materials.
- 31. The process as claimed in claim 23, wherein the polymeric covering and the substrate are combined by pressure.
- 32. The process as claimed in claim 31, wherein the pressure applied is within the range from 1 to 1000 kg/cm^2 .
- 33. The process as claimed in claim 23, wherein the duration of heating is within the range from 0.5 to 3 h.
- 34. The process as claimed in claim 23, wherein the heating temperature is not more than 5°C above the glass transition temperature.
- 35. The process as claimed in claim 23, wherein the substrate and the covering present thereupon are held within the region of the heating temperature for a period of at least 15 min.

- 36. The process as claimed in claim 35, wherein the substrate and covering present thereupon are held within the region of the heating temperature for a period of at least 30 min.
- 37. The process as claimed in claim 35, wherein the holding temperature is within ± 3 °C of the heating temperature.
- 38. The process is claimed in claim 23, wherein the duration of the cooling is at least 1 h.
- 39. The process as claimed in claim 38, wherein the duration of the cooling is at least 2 h.
- 40. The process as claimed in claim 23, wherein the duration of the cooling is up to 30 sec.
- 41. A polymeric constituent with hollow structures present therein, obtainable by a process as claimed in claim 23.
- 42. A polymeric component as claimed in claim 41, wherein the hollow structures comprise closed channels with a width or/and depth of from 10 nm to 10 mm.
- 43. A polymeric component as claimed in claim 41, wherein the interior of the component is free from adhesives.
- 44. The use of polymeric components as claimed in claim 41 in detection procedures, in particular in optical or/and electrical detection procedures.

REMARKS

This application is a national stage filing under 35 U.S.C. § 371 of PCT/EP99/02238. Support for new claims 23-44 is found in the English-language translation of the specification, in the English-language translation of originally filed claims 1-22, and in the translation of the annex to the International Preliminary Examination Report. Applicants request entry of the foregoing amendments.

A check in the amount of \$507.00 is included with this filing to cover the basic national fee, and the fee for two additional claims over 20 claims. Fees have been reduced by half, reflecting applicant's small entity statement. A small entity statement is filed herewith. The Commissioner is hereby authorized to deduct any additional fees associated with this filing from, or credit any overpayment to Deposit Account No. 500624.

Respectfully submitted,

FULBRIGHT & JAWORSKI L.L.P.

David Rubin

Reg. No. 40,314

666 Fifth Avenue New York, New York 10103 (212) 318-3000

			3232-21	121	Wei 18 Sipt
App1	icant	or Patentee:	Stuke et al.		Attorney's HUBR 1165
Seri	al or	Patent No.: _			Docket No.:
_		ssued:	3		
FOL:		ADHESIVE-FF RIFTED STATEM	<u>EE POLYMER COMPONEN</u> FNT (DECLARATION) C	T JOINTS FOR PRODUCING LAIMING SMALL ENTITY ST	CLOSED MICRO- AND NANO
• *				NONPROFIT ORGANIZATION	
				wered to act on behalf	of the
nonp	profit	organization i	dentified below:		
	NAME	OF ORGANIZATIO	N Max-Planck-Ge	sellschaft zur Förderun	g der Wissenschaften e.V.
	ADDRE	SS OF ORGANIZA			
			80539 Münc	hen, Germany	
	יייכנאיזוי	OF ODCANTIZATIO	TAC		
ζ.	1176	OF ORGANIZATIO	5N		
	[]	UNIVERISITY (OR OTHER INSTITUTION	OF HIGHER EDUCATION	
*	[]	TAX EXEMPT U	IDER INTERNAL REVEN	JE SERVICE CODE (26 USC	501(a) and 501 (c) (3))
	[]		ENTIFIC OR EDUCATION	ONAL UNDER STATUTE OF S	TATE OF THE UNITED STATES
		OF AMERICA)
		(CTTATTON OF	ביישויותייב		-)
	[x]	WOULD QUALIFY	AS TAX EXEMPT UNDI	ER INTERNAL REVENUE SER	VICE CODE
	122 1	(26 USC 501(a	a) AND 501(c) (3) II	F LOCATED IN THE UNITED	STATES OF AMERICA
	[]	WOULD QUALIFY	Y AS NONPROFIT SCIE	VTIFIC OR EDUCATIONAL U	NDER STATUTE
				IF LOCATED IN THE UNIT	ED STATES OF AMERICA
		(NAME OF STATE (CITATION OF			 '
		(CITATION OF	SIAIUIE		<u></u> ′
I he	ereby d	leclare that th	ne nonprofit organi:	zation identified above	qualifies as a nonprofit
🖳 orga	nizati	on as defined	in 37 CFR 1.9(e) for	or purposes of paying r	educed fees under section
41 (a	a) and	(b) of Title 3	35, United States Co		invention entitled
·				by inventor(s)	Michael Stuke; described
□ in	<u>Markus</u>	Lapczyna; Kur	t Muller		acserisca
- E	[×]	the specifica	ation filed herewith	n	
offs of the set of the	[]	application :	serial no.	, filed	
A CONTRACTOR OF THE PARTY OF TH	[]	patent no		, filed, issued	and the state of t
= I he	ereby c	declare that r	ignts under contraction with regard to	t or law have been conv the above identified in	eyed to and remain with
he l	thy th	ne nonprofit o	rganization are not	exclusive, each indivi	dual. concern or
org	anizati	on having rig	hts to the invenion	is listed below * and	no rights to the
inve	ention	are held by a	ny person, other th	an the inventor, who co	uld not qualify as small
bus:	iness o	concern under	37 CFR 1.9 (d) or b	y any concern which wou	ald not qualify as a small
bus:	iness o	concern under	3/ CFR 1.9 (d) Or a	nonprofit organization uired from each named p	under 37 CFR 1.9(e). *
Ora	c: sepa	ion having rig	hts to the invention	n averring to their sta	tus as small entities.
	CFR 1.				
NAM:	EESS-				
		1 TNDTVIDUAT.	[] SMALL BUSTNESS	CONCERN [] NONPROFIT	ORGANIZATION
	ι] INDIVIDOAL	[] SMALL BOSINESS	CONCERTA [] NOTE I COLLEGE	CICHALIZATI ION
NAM	E			1	
ADD:	RESS _				
	[] INDIVIDUAL	[] SMALL BUSINESS	CONCERN [] NONPROFIT	' ORGANIZATION
Ιa	cknowle	edge the duty	to file, in this ap	plication or patent, no	otification of any change
in	status	resulting in	loss of entitlement	. to small entity status	s prior to paying, or at
the	time o	of paying, the	earliest of the is	sue fee or any maintena	ince fee due after the
dat	e on w	hich status as	a small entity is	no longer appropriate	(37 CFR 1.28(b))
тh	ereby (declare that a	11 statements made	herein of my own knowle	edge are true and that all
sta	tement	s made on info	rmation and belief	are believed to be true	e; and further that these
c+a	tement	s were made wi	th the knowledge th	at willful false stater	ments and the like so make
ā:::e	punis	hable by fine	or imprisonment, or	both, under section 10	001 of Title 18 of the
Uni	ted St	ates Code, and	that such willful	on, or any patent to whi	eopardize the validity of
		is directed.	item issuing therec	m, or any patent will	ich dais verrieu
sta	ا دکرانکا ا	19 UITECIEU.			
NAM	E OF P	ERSON SIGNING	Christa Herzog		
TIT	LE IN	ORGANIZATION	Head of patent depa	rtment	
ADD	RESS O	W PERSON SIGNI		80539 München	
SIG	NATURE	Christa Herzog	Herzog		
	1	Max-Planck-Ges	ellschaft zur Förde	rung der Wissenschaften	e.V.
				-	

430 Table COT/PTO 2 7 SEP 2000

PCT/EP99/02238

WO 99/51422

Adhesive-free bonding of polymeric components to produce closed micro- and nanochannel structures

Description

5

10

15

20

25

30

The invention relates to a process for producing polymeric components with hollow structures present therein, e.g. in the form of closed micro- or/and nanochannels, said process using no adhesives. The invention further relates to the polymeric parts obtainable by the process and to their use in detection procedures.

Polymeric components, e.g. plastic biochips, interior of which closed hollow structures are present have hitherto been produced by a process in which an adhesive, e.g. a UV-curable adhesive, has been used to bond a plastic outer layer onto a plastic substrate in which depressions are present. However, the use of the adhesive has led to considerable disadvantages. For example, if too much adhesive was applied, capillary interactions caused it to migrate into the channels and render these impassable, at least to some extent. On the other hand, if too little adhesive was used dead spaces were produced directly adjacent to the channels. The process was moreover highly inconvenient, since operations had to be carried out under a microscope. Finally, the presence of the adhesive also impaired the chemical or/and spectroscopic properties of the plastic component.

DE-A-40 22 793 has disclosed that a heated welding tool can be used to weld a polymeric film onto a sheet of polymer in which recesses are present, without prior heating of the sheet of polymer or the polymeric film. The pressure of the welding tool produces a grid of point welds. The welding tool is heated to a temperature of from 250 to 300°C (column 4, lines 63-65), and therefore chemical modification of the

polymeric materials can occur, combined with possible reduction in transparency and/or increase in base-level fluorescence. In addition, undesirable dead spaces are produced adjacent to the welds.

5

10

15

20

1. 7

The object on which the present invention is based was therefore to provide a process for producing polymeric or plastic components provided with hollow structures, said process at least to some extent avoiding the abovementioned disadvantages of the prior art.

This object is achieved by a process for producing polymeric constituents, including the steps of:

- (a) preparing a polymeric substrate which has depressions on at least one surface,
- (b) applying a polymeric covering to a surface present on the substrate and having depressions,
- (c) heating the substrate with the covering present thereupon to a temperature which is at least as high as the glass transition temperature of the substrate or/and of the covering, and
- (d) cooling.

Step (a) of the novel process comprises preparing a polymeric substrate with open depressions on a surface. 25 A covering is applied to this surface with the aim of producing a polymeric component with hollow structures closed on their upward-facing sides. The polymeric substrates and polymeric coverings used for this 30 purpose are selected from the class consisting of meltprocessable thermoplastics, preferably from the class consisting of acrylic polymers, polycarbonates, polystyrenes, and also copolymers and mixtures of these. It is preferably for polymeric substrates and polymeric covering to be selected from among acrylic 35 polymers, such as polyacrylate, polymethacrylate and in particular polymethyl methacrylate polymers polycarbonates.

15

The polymeric substrate has depressions on at least one surface. These depressions preferably have a width or/and depth within the range from 10 nm to 2 mm, particularly preferably from 100 nm to 1 mm and most preferably from 1 μ m to 500 μ m. The depressions preferably comprise structures in the form of channels.

Using the processaccording to the invention, a polymeric covering, for example a polymeric film, is laminated onto this substrate without using adhesives. For this, substrate and covering are preferably selected from among polymeric materials of similar type, in particular from the same polymeric materials. It is moreover preferable for at least the covering and in particular both the covering and the substrate to be composed of optically transparent materials, i.e. materials transparent within the visible or/and UV light regions.

20 produce the substrate with a surface having depressions, a contact mask may first be produced, namely by using a laser to etch the desired microstructures into a silicon membrane under chlorine gas. This contact mask is then laid on the plastic substrate and irradiated with laser light, e.g. with a 25 UV vacuum laser, whereupon ablation cuts the desired channels into the plastic. The depth of cut may be set precisely via the laser and is, for example, 100 nm per irradiation. The resultant channels have a very smooth 30 surface. Removal of the mask then gives the polymeric substrate which can be used for the process according to the invention. As an alternative, the substrates provided with open microstructures may also be produced from a master mold, e.g. by injection molding. 35

Step (b) of the process according to the invention comprises the application of a polymeric covering onto one or more surfaces present on the substrate and having depressions. For this, the surface of the

15

20

25

30

35

polymeric covering, which may also be a film, for example, and the surface of the substrate are prepared in a form which is clean and as smooth as possible. The covering is then preferably positioned on the substrate and the two parts combined by pressure, the pressure applied being preferably within the range from 0.1 to 1000 kg/cm^2 , e.g. from 0.2 to 20 kg/cm^2 .

in step (c) of the process according to the invention, the substrate, with the covering present thereupon, is heated to a temperature which is at least as high as the glass transition temperature of the of substrate or/and the covering. The heating preferably takes place in a controllable heating cabinet, proceeding slowly from the initial temperature (e.g. room temperature) to a value just above the glass transition temperature of one of the polymers. glass transition temperature depends on the heating rate and can readily be determined for various materials by the skilled worker by simple experimentation. The duration of heating is preferably within the range from 0.5 to 3 h, particularly preferably within the range from 0.5 to 1.5 h. heating temperature is preferably within a range between the transition temperature glass and temperature which is 5°C above the glass transition temperature. The heating temperature is particularly preferably within a range between 0.5 and 3°C above the glass transition temperature.

Once the heating temperature has been reached, substrate and the covering present thereupon preferably held for a particular period within

preferably held for a particular period within the range of the heating temperature. This period is preferably at least 15 min, particularly preferably at least 30 min, for example from 40 to 45 min. The holding temperature is preferably within approximately ±3°C of the heating temperature.

Step (d) of the novel process comprises the cooling. The cooling to about 40°C is preferably carried out slowly. The duration of the cooling is generally at least 1 h, particularly preferably at least 2 h and most preferably up to 3.5 h. As an alternative, the cooling may also take place within a few seconds, e.g. up to 30 sec. After the cooling, the finished polymeric part can be removed.

process gives adhesive-free bonding novel form of polymeric coverings, preferably in the structured, preferably films, and transparent polymeric substrate. transparent, sheets of bonding is mechanically and chemically stable. carried out at relatively low can be process temperatures in the vicinity of the glass transition temperature, preferably just above the glass transition temperature. No reaction products are produced, and the process is therefore extremely clean and biocompatible: reduced measurements show no particular, increased fluorescence and no in transparency resultant component. If the covering materials and substrate materials are of the same type, the component produced is composed of just a single material and has optical and electrical properties superior to those of multicomponent systems. The optical quality is so high that it is even possible to detect individual molecules in channels of the components with a good signal/noise ratio.

30

35

25

10

15

20

The present invention further provides a polymeric component with hollow structures present therein, the component being obtainable by the process described above. The hollow structures present in this polymeric component are preferably closed channels, i.e. channels closed on their upward-facing sides, with a width or/and depth of from 10 nm to 2 mm, and the component differs from polymeric parts known from the prior art in that it is essentially or even completely free from

20

25

30

35

adhesives and from thermal reaction products in its interior, in particular in the region of the hollow structures. The novel polymeric part also has full-surface bonding in the region where the surfaces of substrate and covering are in contact, so that no dead spaces are present in the region of the hollow structures. The novel polymeric part may be used for detection procedures, in particular in optical or/and electrical detection procedures.

The invention is further described by the examples below.

Example 1 Production of a polymethyl methacrylate component

A PMMA film is positioned on a surface of a PMMA substrate block, which surface has micronanochannel structures. The surfaces of both parts are clean and smooth. The two parts are placed between two flat sheets of glass, which are then clamped into a press. The pressure applied in the press is within the range from 0.2 to 20 kg/cm², e.g. 2 kg/cm². The entire system is then slowly heated, preferably within a heating time of from 0.5 to 1.5 h, in a controllable heating cabinet, to just above the glass transition The glass transition temperature of the polymer. temperature here depends on the heating rate. The ideal bonding temperature for the heating rate mentioned is 106 ± 0.5 °C.

The system is then held for a period of from 40 to 45 min at a temperature between $104\,^{\circ}\text{C}$ and the ideal bonding temperature. This is followed by slow cooling, preferably for ≤ 3.5 h. After the cooling, the finished structure can be removed from the apparatus. If desired, the cooling phase may also be considerably shortened, down to the seconds region.

Example 2 Production of a polycarbonate component

- 7 -

Using the method described in Example 1, a polycarbonate component was produced. It was found here that this material, too, was suitable for producing components with closed micro- and nanochannel structures.

10

The bonding temperature was within the range from 150 to 160°C.

بن

5

Claims

- 1. A process for producing polymeric constituents, including the steps of:
- (a) preparing a polymeric substrate which has depressions on at least one surface,
 - (b) applying a polymeric covering to a surface present on the substrate and having depressions,
- 10 (c) heating the substrate with the covering present thereupon to a temperature which is at least as high as the glass transition temperature of the substrate or/and of the covering, and
- 15 (d) cooling.
 - 2. The process as claimed in claim 1, wherein

the polymeric substrate and the polymeric covering are selected from the group consisting of acrylic polymers, polycarbonates, polystyrenes, and also copolymers and mixtures of these.

3. The process as claimed in claim 2,

25 wherein

30

35

the polymeric substrate and the polymeric covering are selected from the group consisting of acrylic polymers, in particular of polymethyl methacrylate polymers, or of polymeric carbonates.

4. The process as claimed in any of claims 1 to 3, wherein

the substrate has depressions with a width or/and depth within the range from 10 nm to 2 mm.

5. The process as claimed in claim 4, wherein

the substrate has depressions with a width or/and depth within the range from 100 nm to 1 mm.

v_&

5

6. The process as claimed in claim 5,

wherein

the substrate has depressions with a width or/and depth within the range from 1 μm to 500 $\mu m\,.$

<u></u> 9 -

7. The process as claimed in any of the preceding claims,

wherein

- substrate and covering are selected from among polymeric materials of the same type.
 - 8. The process as claimed in any of the preceding claims,
- 15 wherein

at least the covering is selected from among optically transparent materials.

9. The process as claimed in any of the preceding claims,

wherein

the polymeric covering and the substrate are combined by pressure.

25 10. The process as claimed in claim 9,

wherein

the pressure applied is within the range from 1 to 1000 $\rm kg/cm^2\,.$

30 11. The process as claimed in any of the preceding claims,

wherein

the duration of heating is within the range from 0.5 to $3~\mathrm{h}.$

12. The process as claimed in any of the preceding claims,

wherein

. .

the heating temperature is not more than 5°C above the glass transition temperature.

- 10 -

The process as claimed in any of the preceding 13. 5 claims,

wherein

the substrate and the covering present thereupon the heating are held within the region of temperature for a period of at least 15 min.

10

15

The process as claimed in claim 13, 14. wherein

> the substrate and the covering present thereupon are held within the region of the heating temperature for a period of at least 30 min.

- The process as claimed in claim 13 or 14, 15. wherein
- the holding temperature is within ±3°C of the heating temperature. 20
 - The process as claimed in any of the preceding 16. claims,

wherein

- the duration of the cooling is at least 1 h. 25
 - 17. The process as claimed in claims 16, wherein

the duration of the cooling is at least 2 h.

- 18. The process as claimed in any of claims 1 to 15, wherein the duration of the cooling is up to 30 sec.
- A polymeric constituent with hollow structures 35 present therein, obtainable by a process claimed in any of claims 1 to 18.
 - A polymeric component as claimed in claim 19,

wherein

the hollow structures comprise closed channels with a width or/and depth of from 10 nm to 10 mm.

5 21. A polymeric component as claimed in claim 19 or 20,

wherein

the interior of the component is free from adhesives.

10

22. The use of polymeric components as claimed in any of claims 19 to 21 in detection procedures, in particular in optical or/and electrical detection procedures.

- 12 -Abstract

The invention relates to a process for producing polymeric components with hollow structures present 5 therein, e.g. in the form of closed micro- or/and nanochannels, said process involving no use of adhesives. The invention further relates to the polymeric parts obtainable by the process and the use of these in detection procedures.

-	
ij.	
Hall Rose Brog Bulle	
÷	
F.	
House Head I. The	
#	
1	
A CONTROL OF THE PARTY OF THE P	
I	
Ŀ	

٠			•	Арргоч	ed for use thro	ugh 9/30/98 C	TO/58/01 (4-96) DMB 0651-0032	
Type a plus sign (+) insidi	e this box -+		. F	atent and Tradema	k Office: U.S. I	DEPARTMENT	OF COMMERCE	
			Attor	ney Docket Num	ber	HUBR 116	5	
DECLARA	TION	FOR	First	Named Inventor	Stuk	e, et al.		
UTILITY O				COMP	ETE IF KNO	NWN		
PATENT AF			Appl	ication Number	09/6	47,207		
PATERT A	,		Filing	g Date	Sept	. 27, 200	00 .	
T Declaration OR			Grat	љ Art Unit				
Submitted with Initial Filing		nitted after Filing	Exa	miner Name		•		
the specification of which is adjusted hereto OR X was filed on (MM/DDA)	Ar A	or 1, 1999	of the lan	as Unit	ed States Applica	tion Number or PC	(if applicable).	
I hereby claim foreign priority certificate, or \$285 (a) of enty below and have also identified application having a filing data	benefits under PCT Internation	r Title 35. United St met epolication which ections the box, any	atad Code St design	e §119 (a)-(d) or §365(and at least one count opplication for patent or	o) of any lamight	application(s) for p United States of A sale, or of any PC1	etent or Inventor's Merical Asted Anternational	
Prior Foreign Application (Number(s)		Country		Foreign Filling Date (MM/DD/YYYY)	Priority Not Claimed	YES YES	NO NO	
198 15 632.4 Germany Apr 7, 1998								
Additional fixelon applicati	on numbers s	re listed on a supple	emental p	nicity sheet stached i	eretos			
I hereby cisim the benefit und						on(s) listed bolow.		
Application Number(s				perrry)	Addition applies are find supplies	onal provisional ation numbers led on a prental priority attached hereto.		

Under the Paperwork Reduction Act of 1995, no perions are required to respond to a collection of information unless it displays a valid OMB control number. Burden Hour Statement: This form is estimated to take 0.4 hours to complete. This will vary depending upon the needs of the individual case, Any comments on the amount of time you are required to complete this form should be sent to the Chief Information Officer, Patent and TrademarkOffice, Washington, OC 20231.

DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS, SEND TO: Commissioner of Patents and Trademarks, Washington, OC 20231.

PCT Applicant's Guide - Volume II - National Chapter - US

Please type a plu	Under th) Inside this box ne Paperwork Rec OMB control numb	uction .	Act of 1995, no	persons are	atent and i	rectamark Offi	cer U.S. 1	DEPARI	/30/00. OMB (MARKE
DEC	LAF	RATION		Utility	or D	esig	n Pate	nt A	(pp	licatio	n
United States or information which	PCT Inte	under 35 U.S.C. Listed below an emational applicat erial to patentabili eternational filing	e, mace Ext in th Ly as de	ar as me subje he manner provi efined in 37 CFI	ided by the f R 1.56 which		och of 35 U.S.	C 112 I	arámoud	edge the duty	to disclose
U.S	i. Parer	nt Application		CT Parent			iling Date D/YYYY)			it Patent N <i>If applicab</i>	
Additional (J.S., or PC	ीं न्यंकतास्थ्रांकार्थां स	pplicatio	on rumbers are	Ested on a	supplément	al priority data	sheet P	ro/SB/0	2B attached h	insto.
As a named inve and Trademark (intor, I he Office con	raby appoint the f macted therswith		Customer Number DR	er				-	Place Custo Place Custo Number Bar (Label her	mer Code
	Name			legistered pract Registra <u>Numb</u>	ation	me//6gisara	Man		<u> </u>	Regle	tration nber
							. 4.84				
Additional of Direct all corre			ustome	supplemental F er Number code Label	legistered F	, tactpiones,				attached here	
Name	Fu	lbright	& J	aworski	<u>L.L.</u>	₽				-	
Address	66	6 Fifth	Ave	nue	Charles to A						
Address	Ne	w York,	N.Y	. 10103		- 7		_ -	i		
Ctty	Ne	w York		-		5tate	NY	ZP	1	0103	
Country	US			Telephon		212-31		Fax		-212-752	
believed to be punishable by 1	true; and fine or by	statements mad further that thes prisonment, or b assued thereon.									
Name of Sc	le or F	irst inventor]			A petil	tion has bee	n filed fo	ır this u	nsigned inve	ntor
G	ven Nam	ne (first and mk	idle [if	anyl)	4		Farri	iy Name	or Su	úswe	
The second secon	chael	I Company of the Comp		2/	<u> </u>	<u>s</u> t	tuke				~ ~
inventor's Signature		X E	<u> </u>	! 	<u></u>		- 7)	/	Dete	1X4.
Residence: C	Яly	Götting	<u>en</u>	Siala		Country	y Germ	any		Citizenship	Germa
Post Office A	.ddress	Auf der I	ietr	n 36, 370	77 Gött	<u>tingen</u>	. German	<u>v </u>	•		·
Post Office A	lddress	<u> </u>				_		1			
1		L		ĺ	<u>-</u> _	1	•	C~	intro		



Additional inventors are being named on the

supplemental Additional Inventor(s) sheet(s) PTO/SB/02A attached hereto

บร

rypu a pius	zign (+)	Inside this box -+									 -
DECLARATION ADDITIONAL INVENTOR(S) Supplemental Sheet											
) [] [] []	18	. 1	- 1	A petit	on has been	n filed for this was	igned la	ventor	
liven		al Joint Inventor	M:	iddia Miri	1	Parally	Lapezy			Eunla en la	
Nerveus Nerveus Date × 19.12.00											
inglicienselfi itty	Î			State		Соилгу	Gerw	lany DS	X	Ge	TIMET
out Office A	ddrains	Am Toucker	henze	डागु ध्वी	CX.	- + <u>-</u> -	N3 Cor		THE P		_
ost Office A	40mm	Lavers	tra	se	10	7 3	T78	Wetek	v_{j}	Sern	uny
sky Götel	nge		atata .	Zp			Сансту	Germany			
Name of	Additio	nel Join Invent	or, lf an	1 y :			illen has be	en filed for this 11	nergned	ENTRE	-
Given K	7 <u>2-</u>		te			Family Harte	Mill	or			└
peritor's Signature	×	U. M	ile					Date		492	000
Ragidanica: City	Göt	tingen		State		Courtry	Gemu	my () E)		G(erman
Post Office o	Address"	Brom	peerw	reg 8,	370	77 Göt	tingon;	Genrany	_		
Feet Since /	A cheirpys.										
City (255	tting	-	State	20	•		Chuinny	_Germañ	<u>v</u>		
Name o	Adella	ous joint juveu.	er, il a				בעול מסילום	eren filed for this	insigne	Suntk	
Given Name				Mddle In Mal	<u> </u>	Family Marca				e.p. 3r	
inventori 6 Signatura								tiara			
Flackience:				State		Country			1	Calcanania	
Post Office	ADQUEE.										
Post Office	Address				. –						
City			State	7	a		Country				
Name o	Adam	nakal Joint Isson	tor, if 2		1.		pelding nas	been filled for (his	Unsign:	Po inventor	
Given				15 kg		Family				4,71	
investor's								O and	•		
Realdence: City				State		Country		-		Chizzenetilp	
Post Office	Address										
Post Office	Address	· ·				_			<u>. </u>		
City			3 Carte	7	· I		Country				
7 /4	إنصعر	inventors are be:	ng nam	ed on su	pplen	nantai she	el(s'alla	ched hereto			

(July 1996)